AMENDMENTS TO THE CLAIMS

1. (Currently Amended) A polymer comprising a phenolic monomeric unit of which the phenyl group is substituted by a group A, wherein group A comprises an imide or thioimide group with the exception that A is not

following formulae

wherein X and Y are independently selected from O and S,

wherein each R¹ and R²⁰ to R²³ is a terminal group independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, halogen, -SO₂-NH-R²⁴, -NH-SO₂-R²⁷, -CO-NR²⁴-R²⁵, -NR²⁴-CO-R²⁷, -NR²⁴-CO-NR²⁵-R²⁶, -NR²⁴-CS-NR²⁵-R²⁶, -NR²⁴-CO-O-R²⁵, -O-CO-NR²⁴-R²⁵, -O-CO-R²⁷, -CO-O-R²⁴, -CO-R²⁴, -SO₃-R²⁴, -O-SO₂-R²⁷, -SO₂-R²⁴, -SO-R²⁷, -P(=O)(-O-R²⁴)(-O-R²⁵), -O-P(=O)(-O-R²⁴)(-O-R²⁵), -NR²⁴-R²⁵, -O-R²⁴, -S-R²⁴, -CN, -NO₂, -N(-CO-R²⁴)(-CO-R²⁵), -N-phthalimidyl, -M-N-phthalimidyl, and -M-R²⁴, wherein M represents a divalent linking group containing 1 to 8 carbon atoms,

wherein R²⁴ to R²⁶ are independently selected from hydrogen and an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group,

wherein R²⁷ is selected from an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl and heteroaralkyl group,

wherein a and d are independently 0, 1, 2, 3 or 4,

wherein b and c are independently 0, 1, 2 or 3,

wherein E³ is selected from O, S, NR²⁸ and R²⁹-[L¹⁵]_i-C-[L¹⁶]_j-R³⁰,

wherein L, L¹⁵ and L¹⁶ are independently a linking group, wherein n, i and j independently are 0 or 1,

and wherein one of the groups selected from R¹, R²⁰, R²¹, R²², R²³, R²⁸, R²⁹ and R³⁰ represents the phenolic monomeric unit and the remaining groups represent a terminal group.

2. (Withdrawn) The polymer according to claim 1 wherein the group A has the following formula

wherein X and Y are independently selected from O and S,

wherein L, L^1 and L^2 are independently a linking group,

wherein n, r and s are independently 0 or 1,

and wherein one of the groups R¹, R² or R³ represents the phenolic monomeric unit and the other two represent a terminal group.

3. (Withdrawn) The polymer according to claim 1 wherein the group A has the following formula

wherein X and Y are independently selected from O and S,

wherein G^1 and G^2 are independently selected from O, S, NR^4 and R^5 - $[L^3]_t$ -C- $[L^4]_u$ - R^6 , with the limitation that G^1 is not O or S when G^2 is O and that G^1 is not O or S when G^2 is NR^4 , wherein L, L^3 and L^4 are independently a linking group,

wherein n, t and u are independently 0 or 1,

and wherein one of the groups selected from R¹, R⁴, R⁵ and R⁶ represents the phenolic monomeric unit and the remaining groups represent a terminal group.

4. (Withdrawn) The polymer according to claim 1 wherein the group A has the following formula

wherein X and Y are independently selected from O and S,

wherein G^3 to G^5 are independently selected from O, S, NR^7 and R^8 - $[L^5]_v$ -C- $[L^6]_w$ - R^9 with the limitation that at least one group, selected from G^3 to G^5 , is R^8 - $[L^5]_v$ -C- $[L^6]_w$ - R^9 and that two neighboring groups, selected from G^3 to G^5 , are not represented by O and S, by O and NR^7 , by S and NR^7 or by O and O,

wherein L, L⁵ and L⁶ are independently a linking group,

wherein n, v and w are independently 0 or 1, and

wherein one of the groups selected from R¹, R⁷, R⁸ and R⁹ represents the phenolic monomeric unit and the remaining groups represent a terminal group.

5. (Withdrawn) The polymer according to claim 1 wherein the group A has the following formula

$$\mathbf{E}_{r} + \mathbf{I}_{r} + \mathbf{E}_{r} + \mathbf{E}_{r}$$

wherein X and Y are independently selected from O and S,

wherein G is a group selected from O, S, NR¹⁰ and R¹¹-[L⁹]_x-C-[L¹⁰]_y-R¹²,

wherein L, L^7 , L^8 , L^9 and L^{10} are independently a linking group,

wherein n, x, y, z and r are independently 0 or 1, and

wherein one of the groups selected from R¹, R¹⁰, R¹¹, R¹², R¹³ and R¹⁴ represents the phenolic monomeric unit and the remaining groups represent a terminal group.

6. (Withdrawn) The polymer according to claim 1 wherein the group A has the following formula

wherein X and Y are independently selected from O and S,

wherein E^1 and E^2 are independently selected from O, S, NR^{15} and R^{16} - $[L^{13}]_g$ -C- $[L^{14}]_h$ - R^{17} , wherein n, e, f, g, h, p and q are independently 0 or 1,

wherein e is 0 when E¹ is represented by O, S or NR¹⁵, wherein f is 0 when E² is represented by O, S or NR¹⁵,

wherein L, L¹¹, L¹², L¹³ and L¹⁴ are independently a linking group, and wherein one of the groups selected from R¹, R¹⁵, R¹⁶, R¹⁷, R¹⁸ and R¹⁹ represents the phenolic monomeric unit and the remaining groups represent a terminal group.

- 7. (Canceled).
- 8. (Previously Presented) The polymer according to claim 1, wherein said polymer comprising a phenolic monomeric unit is a novolac, resol or polyvinylphenol.
- 9. (Currently Amended) A heat-sensitive lithographic printing plate precursor comprising a support having a hydrophilic surface and an oleophilic coating provided on the hydrophilic surface, said coating comprising an infrared light absorbing agent and a polymer according to claim 1 comprising a phenolic monomeric unit of which the phenyl group is substituted by a group A, wherein group A has one of the following formulae

wherein X and Y are independently selected from O and S,

wherein each R¹ and R²⁰ to R²³ is a terminal group independently selected from hydrogen, an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group, halogen, -SO₂-NH-R²⁴, -NH-SO₂-R²⁻, -CO-NR²⁴-R²⁵, -NR²⁴-CO-R²⁻, -NR²⁴-CO-NR²⁵-R²⁶, -NR²⁴-CS-NR²⁵-R²⁶, -NR²⁴-CO-O-R²⁵, -O-CO-NR²⁴-R²⁵, -O-CO-R²⁻, -CO-O-R²႑, -CO-R²⁴, -SO₃-R²⁴, -O-SO₂-R²⁻, -SO₂-R²⁴, -SO-R²⁻, -P(=O)(-O-R²⁴)(-O-R²⁵), -O-P(=O)(-O-R²⁴)(-O-R²⁵), -NR²⁴-R²⁵, -O-R²⁴, -S-R²⁴, -CN, -NO₂, -N(-CO-R²⁴)(-CO-R²⁵), -N-phthalimidyl, -M-N-phthalimidyl, and -M-R²⁴, wherein M represents a divalent linking group containing 1 to 8 carbon atoms, wherein R²⁴ to R²⁶ are independently selected from hydrogen and an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl or heteroaralkyl group.

wherein R²⁷ is selected from an optionally substituted alkyl, alkenyl, alkynyl, cycloalkyl, heterocyclic, aryl, heteroaryl, aralkyl and heteroaralkyl group,

wherein a and d are independently 0, 1, 2, 3 or 4,

wherein b and c are independently 0, 1, 2 or 3,

wherein E³ is selected from O, S, NR²⁸ and R²⁹-[L¹⁵]_i-C-[L¹⁶]_i-R³⁰,

wherein L, L¹⁵ and L¹⁶ are independently a linking group, wherein n, i and j independently are 0 or 1,

and wherein one of the groups selected from R¹, R²⁰, R²¹, R²², R²³, R²⁸, R²⁹ and R³⁰
represents the phenolic monomeric unit and the remaining groups represent a terminal group

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- 10. (Previously Presented) The lithographic printing plate precursor according to claim 9, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.
- 11. (Previously Presented) The lithographic printing plate precursor according to claim 10, wherein said dissolution inhibitor is selected from the group consisting of

an organic compound which comprises at least one aromatic group and a hydrogen bonding site,

a polymer or surfactant comprising siloxane or perfluoroalkyl units, and mixtures thereof.

- 12. (Canceled)
- 13. (Previously Presented) The heat-sensitive lithographic printing plate precursor according to claim 9, wherein said coating further comprising a latent Brönsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.
 - 14. (Canceled)
- 15. (Withdrawn) The heat-sensitive lithographic printing plate precursor according to claim 9 wherein the group A has the following formula

wherein X and Y are independently selected from O and S,

wherein G^1 and G^2 are independently selected from O, S, NR^4 and R^5 - $[L^3]_t$ -C- $[L^4]_u$ - R^6 , with the limitation that G^1 is not O or S when G^2 is O and that G^1 is not O or S when G^2 is NR^4 , wherein L, L^3 and L^4 are independently a linking group,

wherein n, t and u are independently 0 or 1.

and wherein one of the groups selected from R¹, R⁴, R⁵ and R⁶ represents the phenolic monomeric unit and the remaining groups represent a terminal group.

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16. (Withdrawn) The heat-sensitive lithographic printing plate precursor according to claim 9 wherein the group A has the following formula

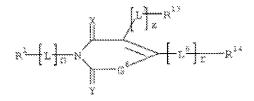
wherein X and Y are independently selected from O and S,

wherein G^3 to G^5 are independently selected from O, S, NR^7 and R^8 - $[L^5]_v$ -C- $[L^6]_w$ - R^9 with the limitation that at least one group, selected from G^3 to G^5 , is R^8 - $[L^5]_v$ -C- $[L^6]_w$ - R^9 and that two neighbouring groups, selected from G^3 to G^5 , are not represented by O and S, by O and NR^7 , by S and NR^7 or by O and O,

wherein L, L^5 and L^6 are independently a linking group, wherein n, v and w are independently 0 or 1,

and wherein one of the groups selected from R¹, R⁷, R⁸ and R⁹ represents the phenolic monomeric unit and the remaining groups represent a terminal group.

17. (Withdrawn) The heat-sensitive lithographic printing plate precursor according to claim 9 wherein the group A has the following formula



wherein X and Y are independently selected from O and S, wherein G is a group selected from O, S, NR^{10} and R^{11} - $[L^9]_x$ -C- $[L^{10}]_y$ - R^{12} , wherein L, L^7 , L^8 , L^9 and L^{10} are independently a linking group, wherein n, x, y, z and r are independently 0 or 1,

and wherein one of the groups selected from R¹, R¹⁰, R¹¹, R¹², R¹³ and R¹⁴ represents the phenolic monomeric unit and the remaining groups represent a terminal group.

18. (Withdrawn) The heat-sensitive lithographic printing plate precursor according to claim 9 wherein the group A has the following formula

wherein X and Y are independently selected from O and S, wherein E¹ and E² are independently selected from O, S, NR¹⁵ and R¹⁶-[L¹³]_g-C-[L¹⁴]_h-R¹⁷, wherein n, e, f, g, h, p and q are independently 0 or 1, wherein e is 0 when E¹ is represented by O, S or NR¹⁵, wherein f is 0 when E² is represented by O, S or NR¹⁵, wherein L, L¹¹, L¹², L¹³ and L¹⁴ are independently a linking group, and wherein one of the groups selected from R¹, R¹⁵, R¹⁶, R¹⁷, R¹⁸ and R¹⁹ represents the phenolic monomeric unit and the remaining groups represent a terminal group.

- 19. (Canceled).
- 20. (Withdrawn) The heat-sensitive lithographic printing plate precursor according to claim 15, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.
- 21. (Withdrawn) The heat-sensitive lithographic printing plate precursor according to claim 16, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.
- 22. (Withdrawn) The heat-sensitive lithographic printing plate precursor according to claim 17, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.
- 23. (Withdrawn) The heat-sensitive lithographic printing plate precursor according to claim 18, wherein said coating further comprises a dissolution inhibitor and wherein said precursor is a positive working lithographic printing plate precursor.
 - 24. (Canceled).
- 25. (Withdrawn) The heat-sensitive lithographic printing plate precursor according to claim 15, wherein said coating further comprising a latent Brönsted acid and an

acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.

- 26. (Withdrawn) The heat-sensitive lithographic printing plate precursor according to claim 16, wherein said coating further comprising a latent Brönsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.
- 27. (Withdrawn) The heat-sensitive lithographic printing plate precursor according to claim 17, wherein said coating further comprising a latent Brönsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.
- 28. (Withdrawn) The heat-sensitive lithographic printing plate precursor according to claim 18, wherein said coating further comprising a latent Brönsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.
- 29. (Withdrawn) The heat-sensitive lithographic printing plate precursor according to claim 19, wherein said coating further comprising a latent Brönsted acid and an acid-crosslinkable compound and wherein said precursor is a negative working lithographic printing plate precursor.
- 30. (Withdrawn) The polymer according to claim 2, wherein said polymer comprising a phenolic monomeric unit is a novolac, resol or polyvinylphenol.
- 31. (Withdrawn) The polymer according to claim 3, wherein said polymer comprising a phenolic monomeric unit is a novolac, resol or polyvinylphenol.
- 32. (Withdrawn) The polymer according to claim 4, wherein said polymer comprising a phenolic monomeric unit is a novolac, resol or polyvinylphenol.
- 33. (Withdrawn) The polymer according to claim 5, wherein said polymer comprising a phenolic monomeric unit is a novolac, resol or polyvinylphenol.

- 34. (Withdrawn) The polymer according to claim 6, wherein said polymer comprising a phenolic monomeric unit is a novolac, resol or polyvinylphenol.
- 35. (Currently Amended) The polymer according to claim [[7]] <u>9</u>, wherein said polymer comprising a phenolic monomeric unit is a novolac, resol or polyvinylphenol.
- 36. (Previously Presented) A method for increasing the chemical resistance of a coating of a positive working heat-sensitive lithographic printing plate precursor against printing liquids and press chemicals, the method comprising providing a coating comprising:

a polymer according to claim 1, an infrared absorbing agent, and a dissolution inhibitor.

37. (Previously Presented) A method for increasing the chemical resistance of a coating of a negative working heat-sensitive lithographic printing plate precursor against printing liquids and press chemicals, the method comprising providing a coating comprising:

a polymer according to claim 1, a latent Brönsted acid, and an acid-crosslinkable compound.

This listing of claims replaces all prior versions, and listings, of claims in the application.